

(-)-(3*S*)-4-(2-[4,4-Dimethoxy-6-(benzyloxymethyl)perhydropyran-2-yl]methyl)-1,3-dithian-2-yl)-4-methyl-3-(1,1,2,2-tetramethyl-1-silapropoxy)-pentan-1-ol

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Received 28 February 2000

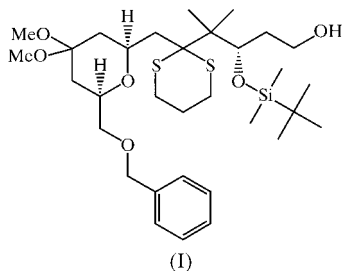
Accepted 2 March 2000

Data validation number: IUC0000056

The absolute configuration was determined for the title compound, (-)-C₃₂H₅₆O₆S₂Si, (I), which was prepared in a synthetic study on the natural products bryostatins. Two independent molecules show similar conformations, except for the orientation of the methoxy groups.

Comment

The absolute configuration was determined for the title compound, which was prepared in a synthetic study on the natural products bryostatins. A synthetic study on bryostatin 3 has been reported (Obitsu *et al.*, 1998).



Experimental

The optically active title compound was prepared by the authors in a synthetic study on bryostatins (Ohmori *et al.*, 2000). The angle of rotation $[\alpha]_D^{22}$ is -6.24° (c 1.0, CHCl₃). Crystals were grown from a hexane/ethyl acetate solution.

Crystal data

C₃₂H₅₆O₆S₂Si
 $M_r = 629.00$
Monoclinic, $P2_1$
 $a = 6.878$ (3) Å
 $b = 19.658$ (3) Å
 $c = 26.493$ (2) Å
 $\beta = 91.33$ (2)°
 $V = 3581.1$ (17) Å³
 $Z = 4$

$D_x = 1.167$ Mg m⁻³
Mo $K\alpha$ radiation
Cell parameters from 25 reflections
 $\theta = 14.3$ – 15.0°
 $\mu = 0.220$ mm⁻¹
 $T = 298$ (1) K
Plate-like, colourless
 $0.7 \times 0.6 \times 0.1$ mm

Data collection

Rigaku AFC-5 diffractometer
 ω scans
Absorption correction: by integration (Coppens *et al.*, 1965)
 $T_{\min} = 0.881$, $T_{\max} = 0.977$
7078 measured reflections
6497 independent reflections
4622 reflections with $I > 2\sigma(I)$

$R_{\text{int}} = 0.030$
 $\theta_{\text{max}} = 25^\circ$
 $h = 0 \rightarrow 8$
 $k = 0 \rightarrow 23$
 $l = -31 \rightarrow 31$
3 standard reflections
every 100 reflections
intensity decay: 1.0%

Refinement

Refinement on F^2
 $R(F) = 0.051$
 $wR(F^2) = 0.130$
 $S = 1.02$
6497 reflections
745 parameters
H atoms treated by a mixture of independent and constrained refinement

$w = 1/[\sigma^2(F_o^2) + (0.0591P)^2 + 1.2827P]$
where $P = (F_o^2 + 2F_c^2)/3$
 $(\Delta/\sigma)_{\text{max}} = 0.017$
 $\Delta\rho_{\text{max}} = 1.00$ e Å⁻³
 $\Delta\rho_{\text{min}} = -0.29$ e Å⁻³
Absolute structure: Flack (1983), no Friedel pairs
Flack parameter = 0.0 (1)

Table 1

Selected geometric parameters (Å, °).

Si1—C10	1.805 (7)	Si3—O8	1.648 (4)
Si1—C13	1.859 (5)	Si3—C36	1.856 (8)
S2—C12	1.807 (7)	Si3—C37	1.864 (10)
S2—C13	1.843 (6)	Si3—C38	1.878 (8)
S51—C60	1.807 (7)	Si53—O58	1.663 (5)
S51—C63	1.861 (5)	Si53—C86	1.845 (8)
S52—C62	1.829 (7)	Si53—C87	1.853 (9)
S52—C63	1.836 (5)	Si53—C88	1.876 (8)
Si3—O8—C33	128.8 (4)	Si53—O58—C83	128.8 (4)

Table 2

Hydrogen-bonding geometry (Å, °).

$D-H \cdots A$	$D-H$	$H \cdots A$	$D \cdots A$	$D-H \cdots A$
O9—H9 ⁱ ···O4 ⁱ	0.97 (5)	2.17 (6)	3.035 (6)	147 (5)
O9—H9 ⁱ ···O7 ⁱ	0.97 (5)	2.41 (4)	3.188 (7)	136 (5)
O59—H59 ⁱⁱ ···O54 ⁱⁱ	0.98 (5)	2.30 (6)	3.096 (6)	138 (5)
O59—H59 ⁱⁱ ···O57 ⁱⁱ	0.98 (5)	2.28 (5)	3.082 (7)	139 (5)

Symmetry codes: (i) $-x, \frac{1}{2} + y, 2 - z$; (ii) $-1 - x, \frac{1}{2} + y, 1 - z$.

Hydroxyl H atoms were located from a difference synthesis and their positional parameters were refined with a restraint of O—H = 0.98 Å (s.u. 0.01 Å) and with $U_{\text{iso}}(\text{H}) = 1.2U_{\text{eq}}(\text{parent atom})$. The other H-atom positional parameters were calculated geometrically and fixed with $U_{\text{iso}}(\text{H}) = 1.2U_{\text{eq}}(\text{parent atom})$. A maximum residual density of 1.00 e Å⁻³ was located 1.11 Å from the C88 atom, suggesting an orientational disorder of the tetramethylsilapropoxy

group. The absolute structure was determined based on a Flack parameter value of 0.0 (1), which is consistent with the expected absolute configuration of 3S produced by Sharpless asymmetric epoxidation protocol. The two independent molecules are related approximately by a translation of (0.47, -0.05, 0.50), except for the methoxy O atoms.

Data collection: *MSC/AFM Diffractometer Control Software* (Molecular Structure Corporation, 1993); cell refinement: *MSC/AFM Diffractometer Control Software*; data reduction: *TEXSAN* (Molecular Structure Corporation, 1999); program(s) used to solve structure: *SIR92* (Altomare *et al.*, 1994); program(s) used to refine structure: *SHELXL97* (Sheldrick, 1997); software used to prepare material for publication: *TEXSAN*.

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